

## EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S16	228	257/758.ccls. and @ad<"20031030" and dummy	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/06/26 00:43
S17	92	257/758.ccls. and @ad<"20031030" and dummy and (CMP or polish\$4) and (cvd or vapor adj deposition)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/06/26 01:12
S18	3	257/725.ccls. and @ad<"20031030" and dummy	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/06/26 01:14
S19	116	438/926.ccls. and @ad<"20031030" and dummy	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/06/26 01:26
S20	19	438/669.ccls. and @ad<"20031030" and dummy	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/06/26 01:26
S21	1118	semiconductor and (wiring or conductor or electrode) and @ad<"20031030" and (dummy with (pattern\$3 or structure or layer or wiring)) and (CMP or polish\$4 or damascene) and (cvd or vapor adj deposition)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/06/26 01:28